

B81B

MICRO-STRUCTURAL DEVICES OR SYSTEMS, e.g. MICRO-MECHANICAL DEVICES (piezo-electric, electrostrictive or magnetostrictive elements per se H01L41/00)

Definition statement

This subclass/group covers:

Encompasses micro-structures:

- Having an electro-mechanical function or a pure mechanical function coupled to an electrical processing circuit suitable for electro-mechanical applications (example of applications: sensors, switches, optical switches, microchannels, micromotors).
- Having a dimension in the range of several microns to a few nanometers, and that are manufactured using a top down process (shaping material, moulding, stamping ...etc.).

Subject-matter belonging to [B81B](#)

Documents which contain one of the following characteristics should be classified in [B81B](#):

- A solution to a technical problem which is common to micro-structures in general (e.g. avoiding stiction, hermetic encapsulation, fabricating structures with high aspect ratio)

Examples:

- Documents that deal with a structure which has no specific application, i.e. which can be used for several application, should be classified in [B81B](#)
- documents that deal with structures that solve a general problem but mention as an example a specific application should nevertheless be classified in [B81B](#) since the invention could also be applied to other applications

Subject-matter excluded from [B81B](#)

- [B81B](#) doesn't cover applications which describe pure biological or chemical material (DNA sensors, carbon nanotubes ...)
- Purely optical or electrical micro- or nano- devices like optical fibers, diodes, transistors, etc.
- Specific systems like pressure sensors, accelerometers, switches,

micromotors, microreactors...etc. without any unspecific aspect/structure which may be applicable to other systems.

- Structures for solving a problem which is specific to a kind of device like increasing the sensitivity of a pressure sensor.

Relationship between large subject matter areas

Limits with application classes (e.g. switches [H01H 1/0036](#))

- If the objective problem solved by the invention is related to improving physical features of the device, or realising a given function, then the document should be classified in the application classes. For example: membrane structure for improving the sensitivity of an acceleration sensor, structure for realising a bi-stable switch, structure for increasing the oscillation frequency of an RF switch.
- If the objective problem solved by the invention is related to fabricating a specific or a general structure, or to a structure for solving a general problem, i.e. a problem that is not specific to a given device, then the document should be classified in [B81B](#). For example: structure for improving the rigidity of a beam.

Limits with Microfluidic applications

Following criteria applies for classifying a document on microfluidic technology in [B81B](#):

- The document describes a general structure (channel, groove, hole, arrangement of microfluidic structures without specific purpose) for use in microfluidic devices.

Following documents are not to be classified in [B81B](#):

- Documents that describe a microfluidic structure which has a specific purpose, where the structure solves a problem specific to the technical field contemplated. For example, a specific arrangement of channels for mixing given liquids (belongs to [B01F 13/0059](#))

Limits with Nanotechnologies ([B82B](#))

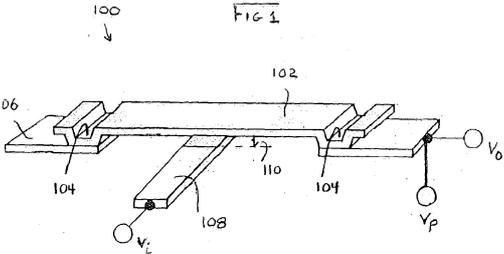
Limit [B81B](#) vs [B82B 1/00](#):

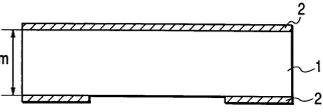
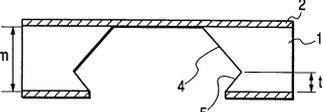
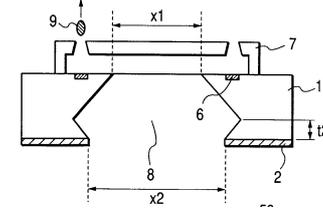
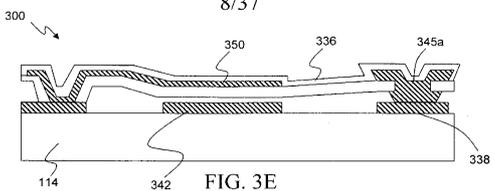
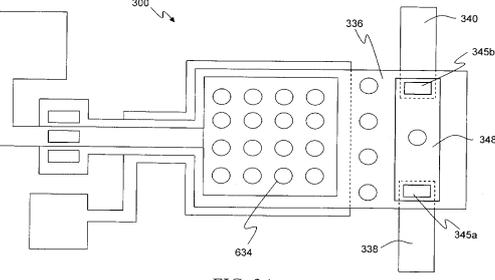
- Nano-structures having exclusively nano-sized components are classified in [B82B](#)
- Nano-structures forming part of a larger structure having at least one micro-sized component are classified in B81

Informative references

Attention is drawn to the following places, which may be of interest for search:

Actuators

Electrostatic motors, electric motors using thermal effect	H02N 1/002 , H02N 10/00
Microphones, microspeakers: Electrostatic transducers using semiconductor materials	H04R 19/005
<p>Networks comprising electromechanical or electro-acoustic devices; Electromechanical resonators. Details of micro-electro-mechanical resonators, Driving or detection means, Comb electrodes</p> 	H03H 9/02244 , H03H 9/2405 , H03H 9/2447
Piezo-electric devices (includes rotory motors, actuators and sensors using a piezo-electric element)	H01L 41/00
Electro active polymer (EAP) actuated artificial muscles	H01L 41/00
Mechanically-driven clocks or watches; mechanical parts of clocks or watches in general N.B.: Processes for making gears (in particular for clocks) are classified in B81C 99/0075+	G04B
Micro pumps	F04B 19/006 , G01N 2035/1034
Micro pumps having electric drive having plate-like flexible members, e.g. diaphragms	F04B 43/043
Ink jet, Nozzles, Production of	B41J 2/1626 , B41J 2/1628 , B41J

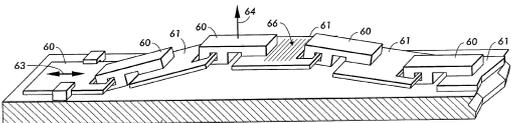
<p>nozzles, manufacturing processes, etching, dry etching, wet etching.</p> <p>FIG. 2 $t=625\mu\text{m}$</p>  <p>FIG. 3 $t=625\mu\text{m}$</p>  <p>FIG. 4</p> 	<p>2/1629</p>
<p>Electrostatic relays; Electro-adhesion relays; making use of micromechanics</p>	<p>H01H 59/0009</p>
<p>Switches making use of micromechanics; Apparatus or processes for their manufacturing, e.g. anisotropic etching (for electrostatic relays H01H 59/0009, for relays in general H01H 50/005)</p> <p>8/37</p> <p>300</p>  <p>FIG. 3E</p> <p>300</p>  <p>FIG. 3A</p>	<p>H01H 1/0036</p>
<p>Micromanipulators</p>	<p>B25J 7/00</p>

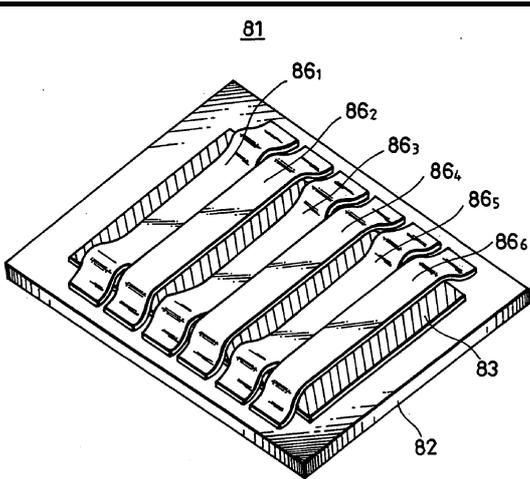
Sensors

<p>Gyroscopes; Turn-sensitive devices</p>	<p>G01C 19/5719</p>
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using gyroscopic effect, e.g. using gas, using electron beam. Turn-sensitive devices with vibrating masses, e.g. tuning fork, the vibrating mass being an essentially two-dimensional body which undergoes a deformation or translation vibration in a micromechanical structure	
Accelerometers, Measuring acceleration; Measuring deceleration; Measuring shock, i.e. sudden change of acceleration	G01P 15/00 , G01P 15/0802
Pressure sensors, manufacturing methods of pressure sensors	G01L 9/0041 , G01L 9/0042
Measuring volume flow or mass flow	G01F 1/6845
IR sensor	G01J 5/00
Arrangements or instruments for measuring magnetic variables (flux or magnetic sensors)	G01R 33/00
Acoustic emission sensors	

Optical devices

<p>Optical switches: Optical devices or arrangements using movable or deformable optical elements for controlling the intensity, colour, phase, polarisation or direction of light, e.g. switching, gating, modulating, the reflecting element being a micromechanical device, e.g. a MEMS mirror, DMD. The reflecting element being moved or deformed by electrostatic means:</p>  <p>by means of one or more diffracting elements:</p>	G02B 26/0833 , G02B 26/0841 , G02B 26/0808
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N.B: Optical devices or arrangements using movable or deformable optical elements for controlling the intensity, colour, phase, polarisation or direction of light are classified in subgroups of [G02B 26/08](#) . In particular MEMS micromirrors and optical devices using them for changing the direction of light are treated in [G02B 26/0833](#) and its subgroups.

Microfluidic and chemical analysis devices or processes

Microreactors, e.g. miniaturised or micro-fabricated reactors	B01J 19/0093
Containers for the purpose of retaining a material to be analysed with fluid transport, e.g. multi-compartment structures by integrated microfluidic structures, i.e. dimensions of channels and chambers are such that surface tension forces are important, e.g. lab-on-a-chip	B01L 3/5027 , B01L 3/5027
Micromixers	B01F 13/0059
Manufacture of fluid circuit elements; Manufacture of assemblages of such elements as integrated circuits (microvalves)	F15C 5/00
Investigating or analysing materials	G01N 27/447

by the use of electric, electro-chemical, or magnetic means. Electrophoresis for analysis in microdevices	
Measuring or testing processes involving nucleic acids (DNA analysis)	C12Q 1/68
Processes specially adapted for manufacturing semi-permeable membranes for separation processes or apparatus, Inorganic membrane formation (micropores)	B01D 67/0039
Microneedles (devices for introducing media into the body) N.B.: Manufacturing methods (other than plastic moulding) for making raised tips (in particular microneedles) are classified in B81C 1/00111 . Methods for coating the needles with an active material for therapeutic purposes is not classified in B81	A61M 37/0015
Microneedles (Devices for taking blood samples by percutaneous method)	A61B 5/1411

Memories

Recording or reproducing by means directly associated with the tip of a microscopic electrical probe as used in Scanning Tunneling Microscopy [STM] or Atomic Force Microscopy [AFM] for inducing physical or electrical perturbations in a recording medium	G11B 9/14
Digital stores characterised by movement of mechanical parts to effect storage, e.g. using balls; Storage elements therefor (storing by actuating contacts G11C 11/48) - RAM with mechanical structure	G11C 23/00
Magnets or magnetic bodies	H01F 1/009

characterised by the magnetic materials therefor; Selection of materials for their magnetic properties. Bidimensional, e.g. nanoscale period nanomagnet arrays.	
Digital stores characterised by the use of particular electric or magnetic storage elements; Storage elements therefor, using electric elements, using ferroelectric elements (using multibit ferroelectric storage elements G11C 11/5657)	G11C 11/22
Read-only memory structures including field-effect components	H01L 27/112

Micromanipulators

Micromanipulators N.B: Documents which comply with the following criteria are to be classified in B81: The micromanipulator is specific to the manipulation and assembling of micro- or nanoparts for MEMS or NEMS. The device solves the problem of surface forces being higher than the gravitational force The document describes the structure and manufacturing process of the micro-manipulator. Methods for controlling the micromanipulator are to be classified in B25J 7/00 only.	B25J 7/00
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Chemistry, nanoparticles, nanowires

Nanowires as interconnects for ICs	H01L 21/768
Nanowires as semiconductor heterojunction of materials of different groups	H01L 29/267
Semi-conductor nanowires / nanotubes / whiskers	H01L 29/0665
Manufacturing method for silicon	H01L 21/30

nanowires / nanotubes / whiskers	
Single crystal growth methods of nanorods and nanowires (deposition)	C30B
Coated nanoparticles for use as pigments and/or fillers	C01G , C09C
Other nanoparticles	C01B 13/00 , C01B 17/00 , C01C , C01F
Semi-conductor nanoparticles	C30B
Nanowires: electrolytic coating by surface reaction, i.e. forming conversion layers	C25D 11/00
Hyperbranched macromolecules	C08G 83/005

Testing and monitoring

Details of semiconductor or other solid state devices, marks applied to semiconductor devices (or parts), e.g. registration marks, test patterns (alignment structures, wafer maps), using circuits for characterising or monitoring manufacturing processes, e.g. whole test die, wafers filled with test structures, on-board-devices incorporated on each die, process/product control monitors or PCM, devices in scribe-line/kerv, drop-in devices	H01L 23/544
Measuring probes, probe needles, cantilever beams, "bump" contacts; replaceable spring loaded probe pins N.B: plugs, sockets or clips are in G01R 1/0408 ; testing of connections in G01R 31/04 ; contacting IC's for test purposes when probe design is not the essential feature in G01R 31/2886 ; using radiation beam as probe in G01R 31/302 ; end pieces for wires terminating in a probe in H01R 11/18	G01R 1/06711

Apparatus for lithography

<p>Photomechanical, e.g. photolithographic, production of textured or patterned surfaces, e.g. printing surfaces; Materials therefor, e.g. comprising photoresists; Apparatus specially adapted therefor, Apparatus for microlithography</p>	<p>G03F 7/00</p>
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Others

<p>Imprinting and embossing machines</p>	<p>B29C 59/00</p>
<p>Control arrangements or circuits, of interest only in connection with visual indicators other than cathode-ray tubes (no fixed position being assigned to or needed to be assigned to the individual characters or partial characters), by control of light from an independent source. Control circuit for an array of optical MEMS, for example for avoiding stiction.</p>	<p>G09G 3/34</p>
<p>Apparatus or processes specially adapted for manufacturing or assembling transformers, inductances, reactors or choke coils, for applying magnetic films to substrates (covering metals, or materials with metals, in general C23C; manufacturing record carriers G11B 5/84), for applying nanostructures, e.g. by molecular beam epitaxy (MBE)</p>	<p>H01F 41/30</p>
<p>Variable MEMS capacitors</p>	<p>H01G 5/16</p>
<p>Injection moulding (for example for micro-needles)</p>	<p>B29C 45/00</p>

Special rules of classification within this subclass

The classification scheme in [B81B](#) comprises two kinds of classification codes:

- The codes [B81B 1/00](#) to [B81B 7/00](#) are the main groups which are defining technical problems solved by the teaching of the classified documents.
- The Indexing Codes [B81B 2201/00](#) to [B81B 2207/99](#) and [B81C 2201/00](#) to [B81C 2900/02](#) are defining technical features of the invention.

Accordingly, the classifier should stick as much as possible to the following rules:

- Each document to be classified in [B81B](#) should be allocated only one main group corresponding to the objective technical problem solved by the invention, unless the content of the document describes more than one invention. In case the classification does not contain a group corresponding to the technical problem, the classifier should allocate either a residual group (see below), or in exceptional cases, when appropriate, several groups that in conjunction describe the technical problem.
- As the invention may comprise several essential technical features, a document classified in [B81B](#) may be allocated more than one Indexing Code. The Indexing Codes which are allocated should be relevant to the invention.
- Furthermore, the Indexing Codes must only be allocated to documents which are receiving a main group

Residual Groups

The classification in [B81B](#) contains so called residual groups. For example:

[B81B 7/0077](#): [N: Other packages not provided for in groups [B81B 7/0035](#) to [B81B 7/0074](#)]

When classifying a document which doesn't correspond to any subgroup (for example [B81B 7/0035](#) to [B81B 7/0074](#)), the document must be classified in the residual group, if present, and not in the main group. In the present example, the documents should be classified in [B81B 7/0077](#) and not in [B81B 7/0032](#).

The classifier must stick to this policy: no new document should be classified in a main group if a residual group is present.

The reason for these residual groups is to provide the search examiner with the certainty, that all documents in the groups have been classified or reclassified. If a residual group is not present, but subgroups are, the examiner has no certainty that the documents from the main group have been reclassified when creating the subgroups.

When doing the search, the presence of the residual group indicates that all documents in the residual group have been classified taking into account the subgroups of the same level. Documents in the group of higher level, which have been split up into the sub-groups, may not have been classified taking into account the sub-groups.

Therefore, at search stage, the examiner must keep in mind that he must verify if documents are present in the main group, since these documents have not been reclassified.

The classification structure in B81.

The classification in B81, based on IPC8, makes the difference between structures and processes. In many cases, the underlying problems, which form the basis for the technical definition of a group, are solved either with a structural solution, or with a manufacturing process. Therefore, some group descriptors are duplicated in [B81B](#) (Structures) and in [B81C](#) (Processes).

The criteria for deciding if a document is to be classified in the structures or in the process is the following:

if the solution to the technical problem is a structure, then the document should be classified in [B81B](#)

if the solution to the technical problem is a method, then the document belongs to [B81C](#)

Example:

[B81B 3/0002](#) . [N: Arrangements for avoiding sticking of the flexible or moving parts]

and

[B81C 1/00912](#) . [N: Treatments or methods for avoiding stiction of flexible or moving parts of MEMS]

If for example, a document describes a process using supercritical CO2 for avoiding stiction, then it should be classified in [B81C 1/00928](#).

If the document describes a bump for avoiding stiction of a cantilever, then it should be classified in [B81B 3/001](#).

Exceptions:

[B81B 3/0005](#) contains also the processes for making anti-stiction coatings

Glossary of terms

In this subclass/group, the following terms (or expressions) are used with the meaning indicated:

Many technical terms in MEMS technology are defined in the SEMI norm

SEMI MS3-0307. In the following sections, some technical expressions are given an additional explanation in the meaning of the classification scheme.

Summary of static of elastic structures:

Defined by their geometry

Extending structures	Pillar / ColumnTip
Depressed structures	Cavity GrooveHole
Suspended structures	Bridge Cantilever Diaphragm See-sawComb structure

Defined by their function

Extending structures	AnchorRib
Depressed structures	ChannelNozzle
Suspended structures	Flexure Membrane Spring Torsion hingeProof mass

Rotating elements

Rotating elements	Gears Rack and pinionHinge
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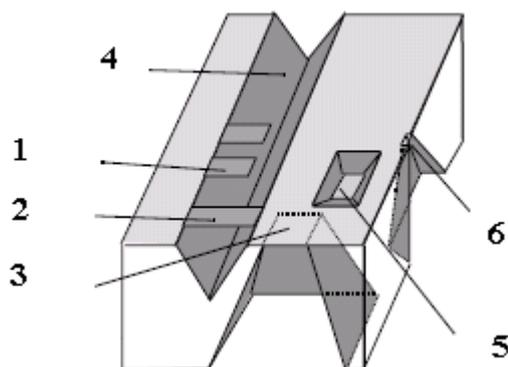
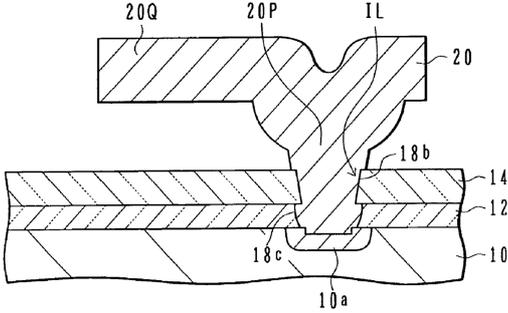


Figure 1: Basic structures

- 1) Cantilever 2) Bridge 3) Diaphragm 4) V-Groove 5) Well/Cavity
- 6) Hole/Nozzle, [1]

Pillar/Column	A tall vertical structure, usually narrow in proportion to its height, which is usually used as a support structure, anti-adhesion structure or a structure for thermal exchange.
Tip	Tips are small pointed or rounded structures often used for Scanning Probe Microscopy probes (SPM) - like atomic force microscope (AFM), but also for data storage (Millipede), electron tunnelling tip (used in sensors) or microneedles.
Bump	is also used in relation to structures for reducing adhesion.
Functional layers	Functional layers are used mostly as protective coatings. They can protect structures against chemical or mechanical corrosion that can release particles into the protected cavity. Special coatings are used also to prevent adhesion of movable structures or to reduce the stress. Metallic layers covering polymer sealing are used to make them hermetic, but can be used also to compensate the RF-interferences.
Anchor	<p>Anchors are structures connecting the suspended movable parts to the substrate. They can affect the resonant frequency and the reliability of the device.</p>  <p>Figure 2 : Anchor (US2005032266)</p>
Rib	Stiffening ribs are may be used to improve the stiffness of suspended structures. Improving the stiffness to

	mass ratio, they can have impact on resonant frequency and efficiency of the devices.
Cavity	In bulk micromachining, cavity is used to make the movement of a suspended element possible. It can be used also for the protection of movable structures in packaging, for thermal insulation or as a container for fluids (see Figure 1). The synonyms are chamber, hollow, well.
Groove	A typical example is a V-Groove (see Figure 1), which can be formed in 100 - Si substrate by KOH etching. Sometimes the groove in 111 - Si substrate is called channel or trench to distinguish them, but we consider channel to be a function oriented definition. Grooves are usually used in microfluidic applications, but can also be used for precise positioning of optical fibres or controlled weakening of structures holding a device prior to its separation by breaking.
Hole	An aperture passing through anything, a perforation, opening.
Channel	A tube or tubular passage, natural or artificial, usually for liquids or fluids.
Nozzle	A spout, mouthpiece, projecting aperture, or a short terminal pipe from which a jet of gas or liquid may issue or be discharged (see Figure 1).
Bridge	A bridge is a structure, erected or suspended over a surface, depression or an obstruction, connecting two or more extremities, including structures with supports deformable in torsion (see Figure 4), flexion or supported by springs (see Figure 5).

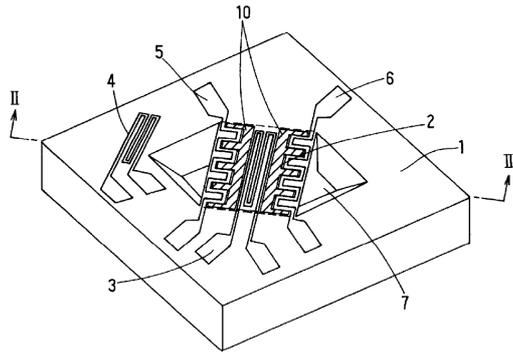


Figure 3 : Bridge (flow sensor: US6626037)

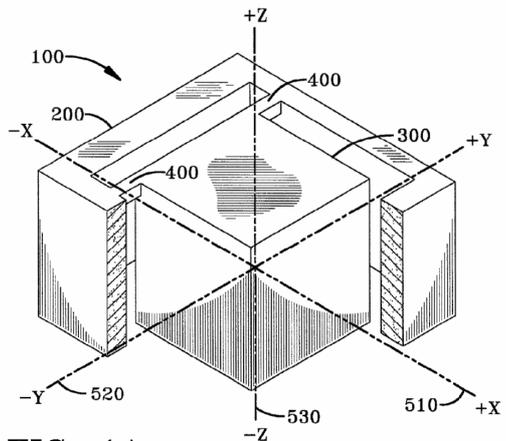


FIG-1A

Figure 4 : Bridge with torsion hinges (accelerometer: EP1431240)

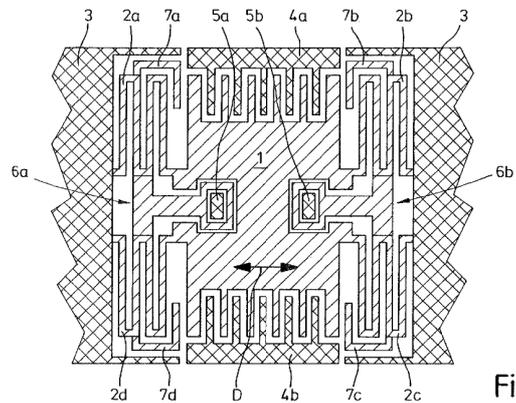


Fig.

Figure 5 : Bridge with springs (inertial sensor: DE10118340) Application : thermal insulation for flow sensors, infra-red sensors, bolometers. According to this definition, most of the accelerometers, gyroscopes and micromirrors are bridges

Cantilever

A cantilever is a structure which projects beyond a supporting column

on a wall and is counterbalanced and/or supported at only one end. Cantilevers are also called flexures, suspension or cantilever beams and suspension springs if their structure is more complicated. These elements usually store and release mechanical energy by deformation resulting in vibration. A proof mass can be attached to one extremity of a cantilever. If there is a cantilever on both sides of a supported structure (proof mass or a micromirror), this structure is called a bridge.

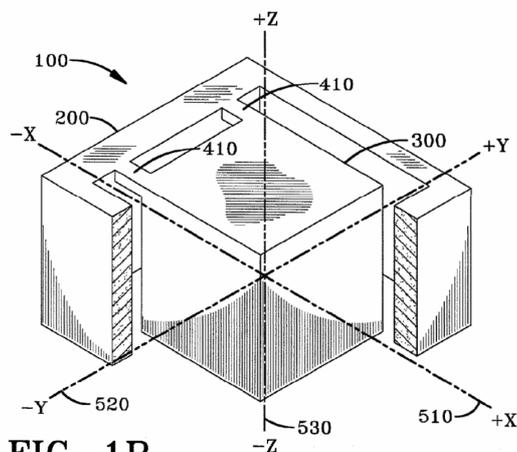


FIG-1B

Figure 6: Cantilever/flexure with proof mass (accelerometer: EP1431240)

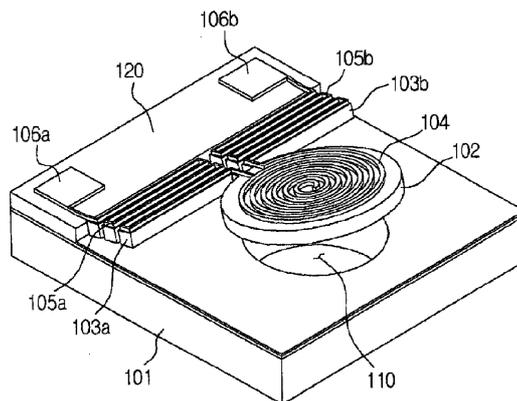
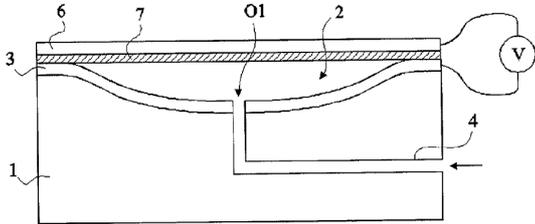
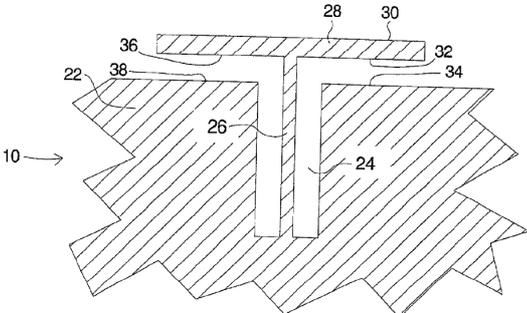


Figure 7 : Cantilever (microvalve: EP1496269)Application: switches, resonators, chemical and biological sensors, accelerometers

Diaphragm

A diaphragm is a layer covering a hole or a cavity, fixed to a frame all along its periphery, separating two

	<p>environments. This separation can be hermetic or not, permanent or temporal and its opening can be controllable. Diaphragms can be perforated or have a seismic mass attached to it.</p>  <p>Figure 8 : Diaphragm (micropump: FR2862629) Applications: pressure sensors, microphones, ultra-sound resonators, valves, accelerometers, thermal insulation</p>
<p>See-saw</p>	<p>See-saw structures are suspended structures supported by a flexible element which main axis is usually perpendicular to the substrate plane. These structures can be used as a support for micromirrors, switches, gyroscopes and resonators.</p>  <p>Figure 9: See-saw (EP1306348)</p>
<p>Comb structure, comb drive</p>	<p>A comb is a structure with a pair of comb-shaped electrodes. This shape increases the total capacitor surface. Comb structures are used for actuation or sensing. When voltage is applied, the combs are attracted to each-other. They are often attached to a deformable element that pulls them back to the initial position because they can not develop a repulsive force.</p>

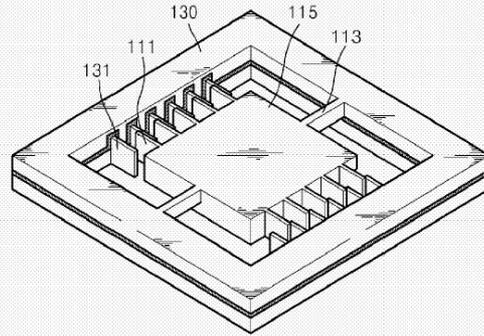
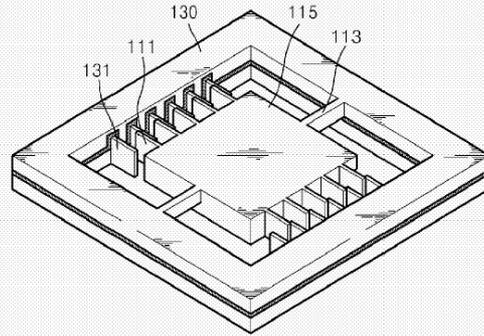
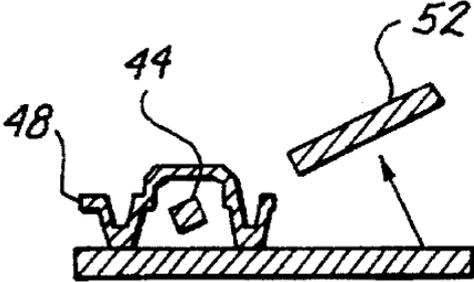


Figure 10 : Comb structure (EP1868024)

	 <p>Figure 10 : Comb structure (EP1868024)</p>
<p>Flexure</p>	<p>Flexure or a flexure beam is a structural element that carries load primarily in bending. Deformation comprises bending about an axis normal to the beam's axis. This allows the structures to move along the perpendicular axis to the substrate (see Figure 6).</p>
<p>Membrane</p>	<p>A membrane is a thin layer separating two environments allowing selective mass transport control, like chemical or physical filtering or separation of substances. Membrane is often used as synonym to diaphragm.</p>
<p>Spring</p>	<p>Spring is a suitably shaped structure that can return to its original shape after a deformation (see Figure 5).</p>
<p>Torsion hinge</p>	<p>Torsion hinge also called deformation hinge or a torsion beam is an element that deforms by twisting about an axis parallel to the beam's axis. This allows the structures to rotate around the axis parallel to the substrate (see Figure 4).</p>
<p>Proof mass</p>	<p>Proof mass also called seismic mass is a structural element usually connected to a deformable element. The mass of this element defines the resonant frequency, sensitivity and precision of the system. In some cases, holes or grooves are made on the proof mass to control or eliminate damping (see Figure 6).</p>

Gears	A gear is a toothed wheel designed to transmit torque to another gear or toothed component.
Rack and pinion	Structure used to transform rotation to translation movement.
Hinge	<p>The movable joint or mechanism to provide for the turning of two movable parts.</p>  <p>Figure 11: Hinge</p>
Interconnects	Electrically conducting element for transmitting a signal from one point to another one. Interconnects that may be formed on, in or through the substrate or any element formed on the substrate (e.g. lid of a package). A via is a particular form of an interconnect.
Electrodes	Electrically conducting element through which an electric current enters or leaves a substance (or a vacuum) whose electrical characteristics are being measured, used, or manipulated. Also terminal points in electrical components.
Thermal actuators	The movement is generated by the difference in thermal expansion of two or more elements (generally beams), each elements having at least one anchoring point to the substrate. A typical thermal actuator is formed out of two parallel beams (one cold beam and one thermal beam) attached at one end to the substrate and having one connecting point at the other end. When the temperature of the thermal

beam becomes higher than the temperature of the cold beam, the difference of thermal expansion generates a deflection at the connecting point.

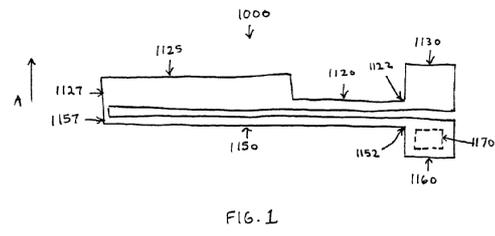


Figure 12 : Thermal beam (US2003002133) Search and Classification Notes: Thermal actuators are also found in [H01H](#).

Bimorph and unimorph actuators

A bimorph is a cantilever that consists of two active layers. These layers produce a displacement via: Thermal activation (a temperature change causes one layer to expand more than the other). Electrical activation as in a piezoelectric bimorph (electric field(s) cause one layer to extend and the other layer to contract). A piezoelectric unimorph has one active (i.e. piezoelectric) layer and one inactive (i.e. non-piezoelectric) layer. For example in the following figure, in response to application of a voltage to the first movable electrode 25, the second movable electrode 26, and the third movable electrode 27, the piezoelectric thin film 1 extends/contracts and the movable section 23 is driven toward the substrate 21.

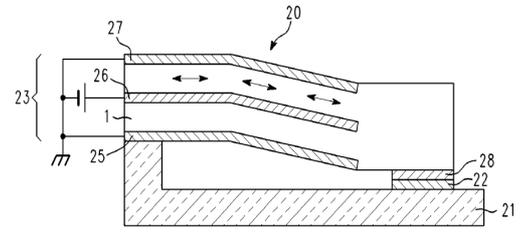


Figure 13 : Bimorph actuator (US2008296529)

B81B 1/00

Devices without movable or flexible elements, e.g. micro-capillary devices

Definition statement

This subclass/group covers:

Structures without a degree of freedom, static structures. A non extensive list of these structures is Pillar / Columns, Tips, Anchors, Ribs, Cavities, Grooves, Holes, Channels, Nozzles.

References relevant to classification in this group

This subclass/group does not cover:

Microneedles (devices for introducing media into the body)	A61M 37/0015
Microneedles (Devices for taking blood samples by percutaneous method)	A61B 5/1411

B81B 3/00

Devices comprising flexible or deformable elements, e.g. comprising elastic tongues or membranes (B81B5/00 takes precedence)

Definition statement

This subclass/group covers:

Structures that are flexible and/or deformable with at least one degree of freedom. A non extensive list of these structures is Bridges, Cantilevers, Diaphragms, See-saws, Comb structures, Flexures, Membranes, Springs, Torsion hinges, Proof mass.

B81B 5/00

Devices comprising elements which are movable in relation to each other, e.g. comprising slidable or rotatable elements

Definition statement

This subclass/group covers:

Arrangement of individual elements which are not connected to each other by a flexible element and that are rotatable or slidable in relation to each other.

Typically gear trains, actuators with a rotor or a sliding part, racks and pinions, hinges.

Relationship between large subject matter areas

Documents describing a single element (like a gear or a wheel) which may be used in a movable structure should NOT be classified in [B81B 5/00](#). These documents may be classified for example in [B81B 1/006](#) or [B81C 99/0075](#)

Informative references

Attention is drawn to the following places, which may be of interest for search:

Micro Dynamo-electric machines, rotary and linear motors or generators	H02K 57/00
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B81B 7/00

Micro-structural systems; [N: Auxiliary parts of micro-structural devices or systems]

Definition statement

This subclass/group covers:

Micro-systems may be either:

- Structural arrangements of functional micro-structures (structures that have a mechanical or electro-mechanical function) with further additional elements which are not directly participating to the mechanical or electro-mechanical function. These further elements may be protecting structures like packages, structures for controlling temperature, interconnects...etc.
- Arrangements of MEMS or of MEMS and discrete electronic components

References relevant to classification in this group

This subclass/group does not cover:

Elements and structures having a main mechanical function in the system.

B81B 7/02

containing distinct electrical or optical devices of particular relevance for their function, e.g. micro-electro-mechanical

systems (MEMS) (B81B7/04 takes precedence)

Definition statement

This subclass/group covers:

The scope of this group has been limited to the following problems:

- Integrating a plurality of different MEMS devices on a single substrate. For example integrating together a pressure sensor and a switch.
- Integrating a MEMS device with discrete electronic components like tunable capacitors, optoelectronic devices, resistors for a switchable resistor array,...etc. on a single substrate
- Interconnecting several different MEMS devices.

References relevant to classification in this group

This subclass/group does not cover:

Integration of a processing unit (circuit that transforms, amplifies, computes...) with a MEMS device (Smart-MEMS)	B81C 1/00222
Networks or arrays of similar micro-structural devices	B81B 7/04

B81B 7/04

Networks or arrays of similar micro-structural devices

Definition statement

This subclass/group covers:

This group relates to systems consisting of an array of structurally identical MEMS devices.